

## Junction Field Effect Transistors (JFETs) Basics - GATE Problems

1. The pinch off voltage for a n – channel JFET is 4 V, when  $V_{GS} = 1$  V, the pinch – off occurs for  $V_{DS}$  equal to
- (a) 3 V (c) 4 V  
(b) 5 V (d) 1 V

[GATE 1987: 2 Marks]

**Soln. Pinch – off voltage ( $V_P$ ) and  $V_{GS}$  (off) are defined as:**

**Pinch off voltage ( $V_P$ ):-** It is the value of  $V_{DS}$  at which  $I_D$  levels with  $V_{GS} = 0$  V.

**$V_{GS}$  (off):-** Value of  $V_{GS}$  that completely pinches – off the current to zero. Magnitude of the two is same i.e.

$$|V_{GS} (off)| = |V_P|$$

When  $V_{GS} = 0$ ,  $I_D$  saturates at  $I_{DSS}$  and characteristic shows  $V_P$ . When external bias is applied gate channel still requires –  $V_P$  to achieve pinch – off. So the relation modifies to

$$|V_{GS}| = |V_P| - |V_{DS}|$$

Where  $V_{DS}$  on LHS is the new  $V_P$  for the applied bias.

In this problem,

$$V_P = 4V$$

$$\& V_{GS} = 1V$$

$$\text{So, } |V_{DS}| = |V_P| - |V_{GS}|$$

$$|V_{DS}| = 4 - 1 = 3V$$

**Option (a)**

2. In an n – channel JFET,  $V_{GS}$  is held constant.  $V_{DS}$  is less than the breakdown voltage. As  $V_{DS}$  is increased
- (a) Conducting cross – sectional area of the channel ‘S’ and the channel current density ‘J’ both increase

- (b) 'S' decrease and 'J' decreases
- (c) 'S' decrease and 'J' increases
- (d) 'S' increases and 'J' decreases

[GATE 1988: 2 Marks]

**Soln. Given,**

$V_{GS}$  is held constant and  $V_{DS}$  is less than breakdown voltage.

Now  $V_{DS}$  is increased, so depletion width increases, thus cross sectional area of the channel decreases,

We know,

$$\text{Current density } (J) = \frac{I}{A} = \frac{I}{S}$$

So, as 'S' decreases current density will increase

**Option (c)**

3. The 'Pinch – off' voltage of a JFET is 5.0 volts. Its 'cut – off' voltage is
- (a)  $(5.0)^{1/2}$  V
  - (b) 2.5 V
  - (c) 5.0 V
  - (d)  $(5.0)^{3/2}$  V

[GATE 1990: 2 Marks]

**Soln. Given,**

**Pinch – off voltage ( $V_P$ ) = 5 V**

We know

$$|V_{GS} (off)| = |V_P|$$

**So cut – off voltage = 5 V**

**Option (c)**

4. Which of the following effects can be caused by a rise in the temperature?
- (a) Increase in MOSFET current ( $I_{DS}$ )
  - (b) Increase in BJT current ( $I_C$ )
  - (c) Decrease in MOSFET current ( $I_{DS}$ )
  - (d) Decrease in BJT current ( $I_C$ )

[GATE 1990: 2 Marks]

**Soln. For BJT**

**Collector current is given by**

$$I_C = \beta I_b + (1 + \beta) I_{CO}$$

**As temperature increases,  $I_{CO}$  increases, so the current  $I_C$  increases in BJT with rise in temperature.**

**Mobility decreases as the temperature is increased.**

**So, in MOSFET, the current ( $I_{DS}$ ) decreases with temperature.**

**As temperature increases  $I_{DS}$  decreases**

**Options (b) and (c)**

5. An n – channel JFET has pinch – off voltage  $V_p = -5 V$ ,  $V_{DS(max)} = 20 V$ , and  $g_m = 2 mA/V$ . The min ‘ON’ resistance is achieved in the JFET for
- (a)  $V_{GS} = -7 V$  and  $V_{DS} = 0 V$
  - (b)  $V_{GS} = 0 V$  and  $V_{DS} = 0 V$
  - (c)  $V_{GS} = 0 V$  and  $V_{DS} = 20 V$
  - (d)  $V_{GS} = -7 V$  and  $V_{DS} = 20 V$

**[GATE 1992: 2 Marks]**

**Soln. For n – channel JFET, the minimum ‘ON’ resistance is obtained when  $V_{GS}$  is positive and large and  $V_{DS}$  is very small, ideally**

$$V_{DS} = 0 V$$

**Since there is no option for  $V_{GS}$  positive, so  $V_{GS} = 0V$ . Thus**

**Option (b)**

6. The transit time of the current carries through the channel of a JFET decides its \_\_\_\_\_ characteristic
- (a) Source
  - (b) Drain
  - (c) GATE
  - (d) Source and drain

**[GATE 1994: 1 Mark]**

**Soln. The transit time of current carriers through the channel of a JFET will decide its drain characteristics**

**Option (b)**

7. In a JFET

**List – I**

- A. The pinch – off voltage decreases
- B. The transconductance increases
- C. The transit time of the carriers in the channel is reduced

**List – II**

- 1. The channel doping is reduced
- 2. The channel length is increased
- 3. The conductivity of the channel is increased
- 4. The channel length is reduced
- 5. The GATE area is reduced

- (a) A – 1, B – 3, C – 4
- (b) A – 2, B – 5, C – 1
- (c) A – 2, B – 3, C – 4
- (d) A – 4, B – 3, C – 1

**[GATE 1995: 2 Marks]**

**Soln. A. Pinch off voltage ( $V_P$ ) is given by**

$$V_P = \frac{q a^2 N_d}{2\epsilon}$$

**So, as doping is reduced Pinch off voltage decreases**

**B. Transconductance ( $g_m$ ) is given by**

$$g_m = \frac{I_D}{V_{GS}}$$

**Thus, transconductance increases as drain current increases as conductivity of the channel is increased.**

**C. If the channel length is reduced then the transit time of the carriers in the channel is reduced**

**Thus, the option is**

A – 1, B – 3, C – 4

Option (a)

8. An n – channel JFET has  $I_{DSS} = 2 \text{ mA}$  and  $V_p = -4 \text{ V}$ . It's transconductance  $g_m$  (in  $\text{mA/V}$ ). An applied GATE to source voltage  $V_{GS}$  of  $-2 \text{ V}$  is

(a) 0.25

(c) 0.75

(b) 0.5

(d) 1.0

[GATE 1999: 2 Marks]

Soln. Given,

n channel JFET

$$I_{DS} = 2 \text{ mA}$$

$$V_{DS} = -2 \text{ V}$$

The expression for  $g_m$  is given as

$$g_m = \frac{2 I_{DSS}}{|V_p|} \left[ 1 - \frac{V_{GS}}{V_p} \right]$$

$$g_m = \frac{2 \times 2 \times 10^{-3}}{|-4|} \left[ 1 - \frac{(-2)}{(-4)} \right]$$

$$= 0.5 \text{ mA/V}$$

Option (b)